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Synthesis, Structural and Magnetic Properties of Copper Doped Cerium Oxide Nanoparticles

Savan Suri

Thesis submitted to the

College of Engineering and Mineral Resources at West Virginia University

in partial fulfillment of the requirements for the degree of

Master of Science

in

Electrical Engineering

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Lane Department of Computer Science and Electrical Engineering

Morgantown, West Virginia

2010

Keywords: Copper, Cerium oxide, Synthesis, Particle size, Paramagnetism & Ferromagnetism In this thesis, synthesis, structural and magnetic properties of the undoped and copper doped cerium oxide nanoparticles have been investigated. The nanoparticles were prepared by sol-gel preparation method. Undoped samples were prepared with different particles sizes by annealing the as-prepared sample at different temperatures $T_a = 200^{\circ}$ C, 400° C, 550° C, 700° C, 800° C. The particle size varied from 3 nm to 42 nm with increasing annealing temperatures. Copper was doped into CeO₂ by annealing the samples at 400° C in ultra high pure nitrogen. The nominal percentages of copper in doped cerium oxide were 2.5%, 5%, 7.5% and 10%.

Structural characterization of the nanoparticles was done using transmission electron microscope (TEM) and x-ray diffraction (XRD). Inductive coupled plasma optical emission spectroscopy was done to detect the impurity concentrations of Iron (Fe) which was found to be present in ppm levels. The nano-particles were found to be nearly spherical in shape in both undoped and doped samples. The particle sizes in undoped samples were found to be increasing with increase in annealing temperatures. As all the copper doped samples were annealed at same temperatures, they were all in the 5 nm size range. The particle size values from XRD and TEM were comparable. Lattice constant and the strain in undoped CeO₂ nanoparticles was found to decrease with increase in particle size. In Cu-doped CeO₂, lattice constant was increasing with increase in doping concentration levels.

Magnetic properties of these nanoparticles were measured using a superconducting quantum interface device (SQUID) magnetometer. Susceptibility and hysteresis loops plots were plotted using magnetization data from SQUID. Increasing paramagnetism was found with decreasing particle size in the undoped samples which is attributed to increase in Ce^{3+} concentration. The small amount of ferromagnetism found in the undoped samples is suggested to originate from the Fe present in ppm levels. In Cu-doped CeO₂ nanoparticles, the paramagnetic and ferromagnetic parts were found to be increasing with increase in doping concentration of Cu in CeO₂. The observed room temperature ferromagnetism in Cu-doped CeO₂ is suggested to result from the effects of copper doping.

Dedication

To my beloved parents...

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1. Introduction

1.1 Motivation and Previous Work

Cerium is a soft gray rare earth element with atomic number 58, atomic mass 140.12 and electronic configuration $[Xe]4f^{1}5d^{1}6s^{2}$. It has a variable electronic structure by which it can change the relative occupancy of electronic levels with only small amounts of energy. This gives rise to its dual valency states i.e. oxidation states of 3^+ and 4^+ . Ionic radius of Ce⁴⁺ is 0.97 Å and of Ce³⁺ is 1.143 Å [1]. It has a crystalline structure with face centered cubic lattice. Cerium oxide (CeO₂) is a stable oxide compound of the cerium. It is also called ceria, ceric (Ce⁴⁺) oxide, and cerium dioxide. Cerium oxide adopts the classic face centered cubic fluorite structure. The unit cell consists of Ce⁴⁺ ions placed in face centered cubic arrangement and oxygen atoms in the tetrahedral interstitials. Sometimes, crystalline CeO₂ exhibits minor defects in which Ce⁴⁺ ions are reduced to Ce³⁺ state in an oxygen deficient state. Lattice parameter of bulk CeO₂ is 0.541nm [2].In CeO₂ lattice structure, Ce⁴⁺ has a coordination number of 8 and O²⁻ has a coordination number of 4. With coordination number 4, oxygen has ionic radius of 1.38 Å [1]. Bulk cerium oxide is diamagnetic in nature. In general, CeO₂ nanoparticles have an advantage of having large surface area per unit volume. Due to their large surface area to volume ratio (with respect to bulk) these nanoparticles have high chemical interaction and reactivity. This is the main purpose of preparing and understanding the ceria particles at the nano scale.



Figure 1: CeO₂ Fluorite Structure

Catalytically, cerium and its oxides are very active as it has attained much attention due to its applications in a number of areas. Due to its ease to switch between Ce^{3+} and Ce^{4+} ionic states, CeO_2 can absorb and release oxygen which is an important catalytic property. And even Ce^{3+} has a high affinity to absorb oxygen [3], a mechanism useful to absorb large amounts of oxygen and release. Due to its extraordinary UV absorption properties cerium oxide nanoparticles are used in cosmetics [4]. It is used as a catalyst in oxygen gas sensors [5], ultra precise polishing, and electronic ceramics. Due its excellent ionic conduction, low conduction activation energy, lower work temperature and lower cost in comparison with zirconia based solid oxide fuel cell (SOFC), cerium oxide is used as a efficient catalyst in SOFC [6].

Many attempts were made by research groups to find magnetism in many of the oxides of metals. In this, transitional metal doped rare earth elements have attained special attention. It has been claimed that even undoped non-magnetic oxides are showing room temperature ferromagnetism at nanoscale. Being a controversial topic of research, nanoparticles of CeO_2 are

claimed to be ferromagnetic instead of being diamagnetic. Bulk CeO₂ is purely diamagnetic. Sundaresan et. al. [7,8] have claimed the discovery of ferromagnetism in nano-particles of nonmagnetic oxides such as CeO₂, Al₂O₃, ZnO, In₂O₃ and SnO₂ at room temperature. The origin of ferromagnetism in these samples is assumed to be due to exchange interactions between localized electron spin moments resulting from oxygen vacancies at the surface of nanoparticles. Liu et. al. [9] also reported ferromagnetism in undoped cerium oxide and found saturation magnetization to be fairly flat and decreasing coercive field with increasing temperature. Using photoluminescence results, Liu et. al. argued that the oxygen vacancies are not responsible for the ferromagnetism observed in size-controlled CeO_2 nanostructures. Fernandes et. al. [10] proposed the possibility of intrinsic point defects as the effective source of RTFM in nanoscale CeO₂. In contrast to previous reports, they report that not only oxygen vacancies are responsible for RTFM, but also that cerium vacancies contribute to the observed ferromagnetic character. Other studies have claimed that experimental artifacts are the reason behind room temperature ferromagnetism in the undoped CeO₂ [9, 10]. Apart from magnetic studies, structural analysis and characterization have also been done on CeO_2 nanoparticles. Tsunekawa et. al. [11, 12] reported lattice expansions with decreasing particles size in nanosized CeO₂ particles. In their theoretical study, they attributed the observed lattice expansion to the decrease of the electrostatic force caused by the valence reduction of Ce ions in the ceria. They also reported increased ratio of Ce³⁺/Ce⁴⁺ concentration with decrease in particle size. Deshpande et. al.[2] have also observed the increase in the lattice constant of CeO₂ nanoparticles with decreasing particles size which is attributed to increase in concentration of Ce³⁺ ions and oxygen vacancies in the crystal. They explain that when Ce^{3+} ion replaces Ce^{4+} ion in CeO_2 structure, a high strain is produced in the lattice which causes the lattice to expand or relax to ease the strain. Zhang et.

al.[13] report that in larger lattice parameter in nanocrystalline CeO_2 indicates smaller emigration enthalpy of an oxygen vacancy, resulting in a higher ionic conductivity and more efficient fuel cells.

Recently, noble metal-free catalysts are beginning to be explored as catalysts due to high cost and less abundance of noble metals. In particular, the basemetals like copper and copperbased catalysts have attracted much attention in heterogeneous catalysis because of their superior catalytic behavior. The redox properties of the copper-ceria interface are proposed to dominate the steam methane reforming (SMR) catalytic activity over Cu/CeO2/y-Al₂O₃ catalysts to produce hydrogen [14, 15]. The enhanced reducibility of copper species is suggested to be responsible for the high catalytic activity for catalyst with low Cu/Ce ratio. Large number of Cuions on the film enhances the catalytic behavior of the catalyst. There is also an urge to produce spintronic devices which needs magnetic semiconductors [16]. The current semiconductor technology, e.g. transistor mechanism, is purely based on the physics and the engineering of charge of an electron. But for controlling the flow of electrons with their spins, instead of the charge, need magnetic semiconductors. Increasing demand for development of multifunctional materials lead to discovery of room temperature ferromagnetism (RTFM) in transition metal doped rare oxides. RTFM has been reported by few research groups with Co, Ni, Fe doped CeO_2 with interesting results [17, 18, 19]. Experimental artifacts, segregation of secondary ferromagnetic phases, magnetic clusters, and indirect exchange mediated by carriers (electrons and holes associated with impurities) have been used to explain the room temperature ferromagnetism in several non-magnetic oxides [20]. An issue whether Cu doped CeO₂ is intrinsically a room temperature ferromagnet or not has received recent attention. Work by Slusser et. al. [21] has reported room temperature ferromagnetism in copper doped cerium oxide

thin films. They have observed a systematic decrease in lattice constant with increase in copper doping concentration. Some of the physical and chemical properties of copper doped cerium oxide have been explained by Wang et. al [22]. Using XRD and density function calculations it was found that parts of the fluorite structure of the cerium oxide was highly distorted with multiple cation-oxygen distances. With increase in copper doping content, increases in surface area, oxygen vacancies, strain in lattice and magnetism have been observed. Catalytic and physico-chemical properties of active sites present in the copper doped ceria have been studied by Kais et. al. [23] by electron paramagnetic studies (EPR) studies. This works explains the EPR studies to prove proper doping of copper into ceria lattice in several annealed samples.

In this work, powder samples of undoped and Cu-doped CeO₂ nanoparticles have been prepared to investigate the structural and magnetic characteristics of the samples in order to verify the recent results on magnetism in Cu-doped CeO₂ thin films [21]. Undoped samples were prepared with particle size variation and Cu-doped samples were prepared with different Cu doping. These powder samples were prepared by the sol-gel technique and the procedure of undoped CeO₂ and Cu-doped CeO₂ (Cu_xCe_{1-x}O₂, x = 0, 0.025, 0.05, 0.075 and 0.10) nanoparticles is described. In the next section, Structural characteristics of the nanoparticles were determined using room temperature x-ray diffraction (XRD) and transmission electron microscopy (TEM). Magnetic properties and electronic state of copper in Cu/CeO₂ nanoparticles were determined using superconducting quantum interference device (SQUID) magnetometer and electron magnetic resonance (EMR) spectroscopy. Results of these investigations on the structural and magnetic properties of undoped and Cu-doped CeO₂ nanoparticles are described in this thesis.

2. Synthesis & Structural Characterization of CeO₂ and Cu-doped CeO₂

2.1 Synthesis

2.1.1 Undoped Cerium Oxide

All the chemical reactions are surface area phenomenon. Larger is the surface area more is the amount of reaction. Smaller particles have larger surface to volume ratio. Therefore for catalytic applications, finer particles of ceria are fabricated to increase surface area in order to enhance the reaction or catalytic efficiency. Usually particles of 1 - 100 nm range are considered to be nanoparticles. The undoped cerium nanoparticles were synthesized using wet chemical solgel process which is a low-cost and low-temperature method. This method also allows one to finely control the chemical composition of the end products. The preparation process consists of gelation of the chemical solution, centrifuging, drying and annealing. Following the procedure used by Liu et al. [9], 4.3414 g of cerium nitrate hexahydrate (Ce(NO₃)₃.6H₂O) (Alfa Aesar 99.5%) is taken into 50ml of 50% distilled $H_2O + 50\%$ polyethylene glycol (Sigma Aldrich, PEG200) and stirred well until the salt is completely dissolved in the solution. Usually solvent plays an important role in determining particle size of the nanoparticles. Next, the solution is heated to 50°C to enhance the chemical kinetics while forming of the gel. If the temperature is too low, the process of gelation will be too slow and if the temperature of the solution is high, thick solid lumps are formed and particles are not well dispersed in the solution. The process is not exothermic; therefore additional heat is needed to fasten the process of gelation. After the temperature becomes constant, 4M sodium hydroxide (NaOH) is added slowly or drop wise into the solution to form the precipitate or the gel. The gel is allowed to form slowly making the nanoparticle network uniform and stronger. Speeding up the precipitation causes to form a weak

and cloudy gel which is non-uniform. The NaOH is added until the pH of the solution is >11. The use of the NaOH is to break the nitrate bonds and form Cerium oxides. Usually acids and bases act as a catalyst and enhance the gelation rate; hence the sol gel process is pH sensitive. When the base comes in contact with the sol, a thick viscous gel is formed on the surface and this blocks the underlying sol to gelate. Hence the solution is to be stirred properly to ensure the complete and uniform gelation of the solution. Sometimes too much agitation or stirring causes breakage of the gel network. However in our case we are not concerned about the nanoparticle network but are concerned only with uniformity of the precipitation. Schematically, the primary chemical reaction involved in the process in shown below.

$$Ce(NO_3)_3.6H_2O + 3NaOH + H_2O + PEG \rightarrow CeO_2 + 3NaNO_3 + 8H_2O + PEG$$
 (2.1)

Note that cerium in cerium nitrate is in +3 state and in cerium oxide it is in +4 state. Now as nanoparticles are precipitated they are centrifuged and separated from the solution. After separation, a grayish paste is left which is dried for 24 hrs at room temperature. After drying, the sample turns into bright yellow cerium oxide (CeO₂) powder which is annealed at temperatures $T_a = 200^{\circ}$ C, 400°C, 550°C, 700°C and 800°C in air for 2 hours each. So in total there are 6 undoped samples to be analyzed viz. as-prepared (25°C), 200°C, 400°C, 550°C, 700°C and 800°C.

2.1.2 Copper doped Cerium Oxide (Cu/CeO₂)

The preparation of copper doped cerium oxide traces the steps for preparing cerium oxide with small changes. Dopant copper is added in atomic proportions with respect to the cerium. copper (II) nitrate hemi(pentahydrate) $Cu(NO_3)_2$. 5/2 H₂O (Alfa Aesar 99.5%) is mixed with cerium nitrate hexahydrate $Ce(NO_3)_3.6H_2O$ (Alfa Aesar 99.5%) in appropriate atomic ratios to

prepare copper doped cerium oxides. $Cu_xCe_{(1-x)}O_2$ where x = 0.025, 0.05, 0.075, 0.1. $Cu_xCe_{1-x}O_2$ with x = 0.025, 0.05, 0.075 & 0.1 will be further denoted in the thesis as 2.5%, 5%, 7.5% and 10% Cu-doped CeO₂ samples. Calculation for amounts to be mixed is given in the Appendix. The amount of samples taken to mix in atomic ratio concentration is given Table 1below.

Cu %	Ce(NO ₃) ₃ .6H ₂ 0 (g)	Cu(NO ₃) ₂ . $2\frac{1}{2}$ H ₂ O (g)
2.5	4.3414	0.0606
5	4.3414	0.1245
7.5	4.3414	0.1918
10	4.3414	0.2628

Table 1: Quantities of Precursors

The above mixtures are taken into a 50ml each of 50% distilled $H_2O + 50\%$ polyethylene glycol (Sigma Aldrich, PEG200) solution and stirred thoroughly until the salts are completely dissolved to form a crystal blue solution. Next the solution is heated to 50°C and 4M NaOH is added drop wise into the solution to form a dark green color gel. The complete process is performed while stirring the solution moderately and maintaining temperature at 50°C. The gel is centrifuged to separate the nanoparticles from the solution. After decanting the solution, a green color paste remains and is dried at room temperature for 24 hrs. After drying, each sample is mixed well and annealed at 400°C for 2 hours in the presence of inert ultra high pure nitrogen. Metals when subjected to high temperatures instantly react with oxygen, sulfur, and other elements and compounds present in atmosphere to form oxides, sulfides etc. Hence annealing in presence of inert atmosphere is very important to preserve the integrity of the metal to be doped and prevent the sample to get impure. So there are 4 samples of Cu-doped cerium oxides prepared viz. 2.5%, 5% 7.5% and 10% copper doped into cerium oxide. Figure 2 shows the flowchart for the preparation of the undoped and 5% doped cerium oxide samples.

2.1.3 Impurity Analysis

Even though lot of care is taken while preparing the sample, contamination is possible in most of the chemical processes. So it is very important to check for any contamination in the prepared samples. As the study is more about magnetic properties of the samples, a test for presence of ubiquitous Iron (Fe) has been conducted using inductively coupled plasma – optical emission spectroscopy (ICP-OES) at Gailbraith Labs Inc., Knoxville, TN. ICP-OES is a highly sensitive technique for elemental analysis to trace impurities to ppm levels. Atoms in plasma emit light with characteristic wavelength for each element. The intensity of the peak gives the concentration of the element. Elemental analysis has been done on an undoped CeO₂ sample and Cu_{0.05}Ce_{0.95}O₂ sample. Results provided by the Gailbraith Lab show that as prepared undoped sample (25° C) has 18ppm of iron concentration and Cu_{0.05}Ce_{0.95}O₂ has 20ppm of iron concentration. These are likely to be present as iron oxides in the precursor salts used for preparation of the samples.



Figure 2: Flowchart for Sample Preparation of Undoped and 5% Cu-doped CeO₂

2.2 Structural Characterization

The structural characterization of the samples was done using X-Ray diffraction (XRD) and Transmission Electron Microscope (TEM). In this characterization, changes in particle sizes, lattice constants and planes participating in diffraction of CeO₂ and Cu/CeO₂ are observed using these techniques.

2.2.1 Transmission Electron Microscopy (TEM)

Transmission electron Microscope (TEM) uses a beam of highly energetic electrons to examine materials on the micro to nano scale. TEM overcomes the limitations of light microscope (due to its wavelength of 400nm-750nm) with magnification of only 500x - 1000x and a resolution of 0.2 micrometers. TEM functions exactly as their optical counterparts that it uses a focused beam of electrons as light source at much lower wavelength of energetic electrons and makes it possible to get a resolution of thousand times better than with a light microscope to gain detailed information on its structure and composition of the materials. If an electron with mass *m* is accelerated through a potential eV (V in volts), then wavelength of the electron is

$$\lambda = \sqrt{\frac{h^2}{2meV}} = \frac{1.23nm}{\sqrt{V}} \tag{2.2}$$

Thus for an accelerating voltage of 100V, wavelength of the beam will be just at atomic scale to get diffracted by electrons. A bunch of electrons is created in ultra high vacuum using electron guns. This bunch is accelerated towards the specimen placed at positive electrical potential. Before hitting the sample, the electron beam is focused into a thin, monochromatic beam by the condenser lenses, which also control the brightness of the beam, and condenser aperture. The electrons which are elastically scattered transmit through the sample and pass through objective lens which forms the image display. If the sample is too thin there will be little

diffraction and if the sample is too thick there will be too much of scattering which gives blurred image. Objective area aperture and selected area aperture are used to choose elastically scattered electrons. Finally the beam goes into projector lens which expands the beam onto a phosphor screen or seen in a monitor.



Figure 3: Transmission Electron Microscope

Different kinds of images can be produced by controlling the apertures and types of interacted electrons. Basically three kinds of electrons participate during the interaction First are the unscattered electrons which transmit through the sample without any interaction giving Bright Field Image. Second are the elastically scattered electrons i.e. diffracted electrons which show diffraction patterns. These patterns can yield information about orientation, lattice arrangements and phase of the examined sample. Dark Field Images are obtained if diffracted beams are selected by the objective aperture. Third one is inelastically scattered electron which

can be utilized for electron energy loss spectroscopy (EELS) and Kikuchi bands. The operation of TEM requires an ultra high vacuum environment under a high voltage. In transmission microscopy, sample's structure and atomic columns can be physically seen giving the compositional and crystallographic information.

2.2.1.1 TEM Data analysis

TEM micrograph image gives information about the particle sizes and their morphology. Images in Figure 4 show that most of the nanoparticles are nearly spherical in shape and the atomic planes show the crystallinity of the particles. Sizes of approximately 10 - 15 particles have been measured and an average has been taken. Figure 4 (a) shows the bright field image of undoped CeO₂ sample annealed at $T_a = 400^{\circ}$ C. Similarly, bright field images of 2.5%, 5%, 7.5% and 10% Cu-doped CeO₂ have been shown in figures 4(b), 4(c), 4(d) and 4(e) respectively. As all the above samples are annealed at same temperature similar particle sizes are expected for each of them. Table 2 shows the average particle size of the undoped and doped CeO₂ samples.

Cu %	Avg. Particles Sizes (nm)
$0 (T_a = 400^{\circ}C)$	6.5 ± 0.5
2.5	7.0 ± 0.6
5	5.5 ± 0.6
7.5	5.3 ± 0.5
10	6.6 ± 0.4

Table 2: Average Particle Size using TEM Analysis





Figure 4: TEM images of (a) Undoped Sample (132nm x 132nm), (b) $Cu_{0.025}Ce_{0.975}O_2$ (132nm x 132nm), (c) $Cu_{0.05}Ce_{0.95}O_2$ (52nm x 52nm), (d) $Cu_{0.075}Ce_{0.925}O_2$ (52nm x 52nm), (e) $Cu_{0.1}Ce_{0.9}O_2$ (52nm x 52nm)

2.2.2 X-Ray Diffraction (XRD)

X-Ray diffraction is a powerful elemental analysis technique which relies on Von Laue's discovery (1912) of x-ray diffraction by crystalline substances. These diffracted rays give us the information on structural arrangement of atoms in the matter. X-ray is a part of electromagnetic wave spectrum with wavelength of 0.01 to 10nm (for visible its 390-750nm). X-rays with wavelength 0.2 to 2.5 Å are used for diffraction studies. They exhibit dual nature i.e. in some conditions behaving like a particle and in other conditions behaving like wave. The theoretical

explanation on XRD in this section is based on the book "X-ray diffraction procedures for polycrystalline and amorphous materials" by H.P. Klug and L.E. Alexander [24]. The X-ray technique mainly consists of an x-ray emitter, sample holder and detector.

X-rays are generally produced by two types of interactions between atoms and incoming high speed electrons. One being when a high speed electron collides with a target atom it dislocates a tightly bound inner core electron by exciting the atom. The excited atom deexcites when an electron from outer shell falls into the vacant inner shell and releases an x-ray. The energy of this photon is the difference between the transition levels and has characteristics unique to the atom involved.



Figure 5: Production of X-Rays

Another way of producing an x-ray is when the high speed electron is slowed by the electromagnetic force of a nucleus of an atom. The reduced energy ΔE changes into x-ray photon with frequency v.

$$\Delta E = hv$$
, where v is Planck's constant (2.3).

X-rays produced like this are independent of the atoms being bombarded. Spectrum consists of two parts, a continuous spectra composed of wide band wavelengths called *white or general radiation* resulting from the deceleration of the high-energy electrons by the electric fields of the target atoms. It becomes more intense and shifts towards higher frequencies when the energy of the accelerated particles is increased. When a high enough voltage is applied, *characteristic radiation* lines are produced which superimpose on the continuous background. These peaks are characteristic to the element and the order of length of wavelength produced by atomic shells is N > M > L > K. For a K shell vacancy, if an L shell electron fills the vacancy K_{α} line is emitted and if M shell electron fills the vacancy K_{β} line is emitted. K_{α} is more intense and longer wavelength line and has two closely bounded lines or doublets $K_{\alpha 1}$ and $K_{\alpha 2}$ with intensity ratios 2:1 respectively. Similarly, K_{β} is less intense and is a lower wavelength line which also has doublets $K_{\beta 1}$ and $K_{\beta 2}$. This is shown in figure 6 below. Usually K_{β} lines are filtered in XRD studies due to their low intensities. Similarly, filling L shell vacancy emits L series lines. The wavelength of the emitted photon depends on the transition level and element used at anode.



Figure 6: Energy Lines from Different Levels

Emitted X-rays are filtered to make it monochromatic i.e. allowing only useful K_{α} lines and removing K_{β} , continuous and even fluorescent X-rays and also collimated before the radiation strikes the sample. This removes unnecessary and harmful radiation and simplifies the data analysis. The produced x-rays are directed towards the sample and get diffracted from the sample without change in the wavelength (coherent or Bragg Scattering). The diffracted X-rays are detected using a detector which determines the quality, reliability and throughput of the pattern. The position and intensity of the observed peaks in the diffraction pattern lead to knowledge of fundamental properties like size, shape and orientation of the unit cell.

Element	Κα1	Κα2	Unresolved K _α	$K_{\beta 1}$	Excitation
	(Å)	(Å)	(Å)	(Å)	Potential
					(kV)
Ag	0.5594	0.5638	0.5608	0.497	25.52
Mo	0.7093	0.7135	0.7107	0.6322	20.00
Cu	1.5405	1.5443	1.5418	1.3806	8.98
Ni	1.6579	1.6617	1.6591	1.4881	8.33
Со	1.7889	1.7928	1.7902	1.6082	7.71
Fe	1.93604	1.9399	1.9373	1.7435	7.11
Cr	2.2897	2.2936	2.291	2.0702	5.99

Table 3 : Targets often used in X-Ray Diffraction Studies

The most useful range of wavelength for diffraction purpose is 0.56 to 2.29 Å. Elements like Ag, Mo, Cu, Co, Fe Cr and Ni falling in this range are used to produce x-rays for diffraction studies. Table 3 shows the targets often used in x-ray diffraction studies [24]. The radiation from lower atomic number elements is readily absorbed by windows and air. The heavier atoms produce highly intense radiation which is harder to process. The most commonly used element for XRD studies is copper due to strong K_{α} and K_{β} lines and its high thermal conductivity which helps to cool while operation. The wavelength of the radiation emitted corresponding to the minimum voltage required to excite an atom is called *quantum wavelength*. Wavelength limits of

the radiation and the distribution of the intensity within are determined by the magnitude of the applied voltage. With increasing potential on the tube, intensity of the wavelengths also increases. Practically voltages far higher than critical excitation voltage are applied to get optimum intensity of the characteristic lines with respect to continuous spectrum. According to theoretical studies of Witty and Wood [25], a factor of 3.5 to 5 is practically used with respect to critical excitation voltage. For example excitation potential of copper is 8.98kV. But for practical diffraction application 30-50kV of voltage is used. Table 3 shows some of the elements used in diffraction studies and their respective excitation voltages.

Room temperature XRD patterns were taken on Rigaku diffractometer with CuK_{α} radiation with a wavelength of 0.5418nm. Data scans were taken from 5° to 100° in 0.06° steps with a time interval of 5 seconds. Applied voltage was 30kV and filament current was 40mA. Studies were carried on samples annealed at $T_a = 25^{\circ}C$, 200°C, 400°C, 550°C, 700°C and 800°C for undoped CeO₂ as shown in Figure 8. Also XRD studies were done on $T_a = 400^{\circ}C$ annealed samples of Cu_xCe_{1-x}O₂ with x = 0.025, 0.05, 0.075 and 0.1 showed in Figure 9. Note that from Figures 8 & 9, the intensity of the peaks can be related to the intesity factors described above especially with atomic structure factor. In Figure 7, XRD patterns of undoped samples clearly show no formation of any impurities apart from crystalline CeO₂. Similalrly, Cu doped samples show no phase of copper or any other oxides of copper suggesting successful doping of copper into CeO₂ lattice. All peak in undoped and doped samples were matched to the cubic CeO₂ reference lines obtained using PDF# 01-73-6328 in ICDD powder diffraction database.



Figure 7: XRD Patterns of Undoped CeO₂



Figure 8: XRD Patterns of Cu-doped CeO₂

2.2.2.1 Particle Size Calculations

As mentioned above, X-ray diffraction can be used to calculate the grain sizes of the particles. Modified Debye -Sherrer relation or Williamson-Hall relation [26] is used to evaluate the size and strain broadening by measurement of peak width. The Williamson-Hall relation is,

$$\beta \, Cos\theta = \eta Sin\theta + \frac{o.89\,\lambda}{D} \quad where \, \beta^2 = \beta_M^2 - \beta_s^2 \tag{2.9}$$

where β is corrected full width at half maximum (in radians), θ is angle of diffraction (in degrees), η is the strain in the lattice, λ is the wavelength of incident beam (1.5418Å), D is the calculated grain size, β_M is the FWHM of the measured peak in the pattern and β_S is the FWHM of a standard sample (SiO₂) representing instrumental width [32]. In Figure 7, the width of peaks of undoped CeO₂ samples reduces with increase in annealing temperatures suggesting that particle sizes tend to become larger with increasing annealing temperatures due to thermodynamically driven Oswald ripening. From the above equation (2.9), reduction in peak widths infers increase in particle size and/or reduction in strain. Since all Cu-doped samples are annealed at same temperature, peak widths of the samples are unchanged. As the grain size becomes larger and larger, the FWHM of the diffraction peaks become smaller and smaller and at a stage it will be nearly equal to instrumental width β_s . This produces large errors in β and so D cannot be calculated accurately. Therefore, this relationship can be used only for the samples with crystalline sizes less than ~ 100nm. Using the plot $\beta Cos\theta$ vs Sin θ , D is determined from the intercept $(0.89\lambda / D)$ and the strain (η) from the slope. Figure 10 and figure 12 show the $\beta Cos\theta$ vs $Sin\theta$ plots for undoped and doped samples respectively with the calculated values of D and η shown in Tables 5 and 6.



Figure 9: βCosθ vs Sinθ Plots for Undoped CeO₂ Samples

T _a (°C)	Particle Size (nm) (D)	Strain (10 ⁻³) (η)
25	2.9 ± 0.3	-31.3 ± 1
200	3.3 ± 0.2	-23.7 ± 0.2
400	5.7 ± 0.8	-7.2 ± 0.6
550	6.4 ± 0.3	-5.8 ± 0.3
700	19.7 ± 0.9	0.9 ± 1.2
800	41.6 ± 0.5	-1.7 ± 0.7

Table 4: Particle Size and Strain for Undoped CeO₂ Samples from XRD Patterns

As expected it can be observed from Table 5 that annealing the samples to higher temperatures has caused increase in particle size. Again increase in particle size is due to Oswald ripening where smaller particles dissolve over time to reform into a larger particle while heating. And this formation affects the strain in the sample. It can be observed a uniform decrease in strain with increasing particle size. Larger particles have lower surface area per unit volume thus reducing the strain. High strain in the lattice may lead to lattice expansions to relieve the strain. Figure 11 shows the variations in particle size and strains of undoped samples with respect to annealing temperature (T_a).



Figure 10: D vs T_a & η vs D Plots of Undoped CeO₂



Figure 11: βCosθ vs Sinθ Plots of Cu-doped CeO₂ Samples

Cu %	Particle Size (nm)	Particle Size (nm)	Strain (10⁻³)
	(XRD)	(TEM)	(η)
2.5	5.2 ± 0.3	7.0 ± 0.6	-6.5 ± 0.4
5	5.5 ± 0.3	5.5 ± 0.6	-3.9 ± 0.6
7.5	4.4 ± 0.5	5.3 ± 0.5	-9.7 ± 0.1
10	5.3 ± 0.1	6.6 ± 0.4	-5.3 ± 0.5

Table 5: Particle Size and Strain of Cu-doped CeO₂ Samples

Table 6 shows the particle size and strain calculations for Cu-doped cerium oxides. As all the samples are annealed at same temperature ($T_a = 400^{\circ}$ C) there is no significant difference in the size of the particles. TEM calculates physical particle size and XRD calculates grain size. At nanoscale grain size and particle size are considered to be almost equal. TEM and XRD data match to an extent with difference of 1nm approximately. No systematic change in strain has been noticed with Cu-doping concentration whereas Wang et. al. [22] have reported increase in strain with increasing Cu-doping concentration.

2.2.2.2 Lattice Constant

Planes in crystalline structure contribute to diffraction of the x-rays. The x-ray interaction with crystalline planes can be explained using Bragg's law, one of the groundbreaking principles on which x-ray diffraction study is based. A simple geometric interpretation for constructive interference was given by William Lawrence Bragg in 1912. According to Bragg's law, when a monochromatic radiation of wavelength λ strikes the atomic planes with spacing *d* and with an angle θ then,

$$2dSin\theta = n\lambda \tag{2.10}$$

i.e. the path difference between the waves reflected by successive planes should be an integral multiple of the respective wavelength $(n\lambda)$ for diffraction to occur. This is the one of the conditions for maximum intensity. As mentioned above cerium oxide has a fluorite structure i.e. it is a cubic system. Using simple geometry, the relationship between the lattice constant (a) i.e. the distance between the atoms in a diffracting plane and the distance between diffracting planes d_{hkl} in a fluorite structure is

$$a = d_{hkl}\sqrt{h^2 + k^2 + l^2}$$
(2.11)

where (*hkl*) is the corresponding Miller indices of the plane. Using equations (2.11) and (2.12),

$$n\lambda = a \frac{2 \sin\theta}{\sqrt{h^2 + k^2 + l^2}} \tag{2.12}$$

In Figure 12, the rays scattered at A and B must be in phase for a constructive interference. The path difference CB + BD must be an integral multiple of the incident wavelength.



Figure 12: Bragg's Law

From equations 2.11 & 2.12, variations in the lattice constant (*a*), d-spacing of the planes of the cerium oxide crystal can be calculated which helps to understand the mechanism of doping in the lattice. All the calculations have been done with reference to (220) peak. Table 7 & 8 show the lattice constant values of undoped and Cu-doped cerium oxides respectively.

T _a (°C)	Lattice Constant (Å)
25	5.467 ± 0.001
200	5.467 ± 0.001
400	5.466 ± 0.001
550	5.465 ± 0.001
700	5.454 ± 0.001
800	5.453 ± 0.003

Table 6: Lattice Constant Values of Undoped CeO₂ Samples



Figure 13: Plot for Lattice Constant vs Particle Size for Undoped CeO₂ Samples

From particle size measurements for undoped samples, it has been found that with increasing annealing temperatures the particle sizes increases (Figure 13). With increment in particle size decrement in d-spacing (d) is observed. As d-spacing is directly proportional to lattice constant (a), with annealing temperatures there is a decrease in lattice constant (a). The same phenomenon was reported by Tsunekawa et. al. [11,12]. Zou et. al. [27] suggested that surface stress on ceria particles may be the reason behind the change in the lattice parameter.

Cu %	Lattice Constant (Å)
2.5	5.4606 ± 0.0005
5	5.4638 ± 0.0006
7.5	5.4785 ± 0.0003
10	5.4620 ± 0.0009

Table 7: Lattice Constant Values of Cu-doped CeO₂



Figure 14: Lattice Constant vs Doping % Plot of Cu-doped Samples

In Cu-doped samples, with increasing Cu-doping percentage increase in lattice constant has been observed up to 7.5% and at 10% there is a sudden decrease. In many transition metal doped semiconductor oxides systems, the dopants substitutionally occupy host sites at lower concentrations only and above a certain limit, additional interstitial incorporation of dopant occurs [28]. This might be one of the reasons for sudden change at 10%. However, no uniform change in particle size has been noticed with changing doping concentrations.

2.2.2.3 Intensity of Lines and Structure Factor

In this section factors affecting the intensity of CeO_2 peaks in XRD spectrum are briefly discussed. The analysis is based on the atomic positions of cerium and oxygen atoms in the crystal lattice. In powder X-ray diffraction, the intensity *I* is given by [24]

$$I = |F_{hkl}|^2 * p * \frac{(1 + Cos^2 2\theta)}{sin^2 2\theta \cos\theta} * PO * \mu$$
(2.4)

where F_{hkl} is structure factor = $\sum_{j=1}^{N} f_j e^{-M_j} exp\{2\pi i(hx_j + ky_j + lz_j)\}$

In the above equations, f_j is the atomic scattering factor of the j^{th} atom with coordinates (x_j, y_j, z_j) in the unit cell, (hkl) is the Miller indices, F_{hkl} is the atomic structure factor, p is the multiplicity factor, $(1+\cos^2 2\theta)/(\sin^2 2\theta \cos \theta)$ is the Lorentz-polarization factor, $exp(-M_j)$ is the Debye – Waller temperature factor, PO is the preferential orientation factor and μ is the absorption factor. A brief note on all the factors is discussed below. Atoms possess some finite sizes which are of the same magnitude as of the wavelength of an x-ray and the intensity of the scattering is directly proportional to the number of electrons in an atom. As the electrons are not concentrated at a point but scattered in the volume of the atom, the diffraction has a partial destructive interference and hence a net reduction in intensity of the radiation is observed. Atomic scattering factor (f_j) is the ratio of the amplitude of the coherent scattered radiation from an atom to that from a single electron situated at the atomic center. For $\theta = 0$, f_j is maximum and equals to atomic number (Z) of the atom. As θ increases, wave scattered by individual electrons become more and more out of the phase and eventually f_j decreases. Therefore *intensity of the lines at higher angles tends to be smaller* in general as shown in figure 15.



Figure 15: Atomic Scattering Factor

The characteristic radiation from an x-ray tube is considered to be unpolarized, but such radiation after being scattered or diffracted is polarized. The amount of polarization depends on the angle through which it is scattered or diffracted. More polarize is the beam more is the intensity seen in the spectra. For powder diffraction, polarization factor is $(1+cos^22\theta)$. Beam divergence and polychromatism contribute to the plane's chance to reflect by virtue of its orientation or length of time it is position to reflect. Lorentz factor arises from the fact that the area of the peak depends on the value of θ involved. The intensity is proportional to $1/Sin^2\theta$ called polychromatic Lorentz factor. Therefore as 2θ increases, the intensity of the peaks in the diffraction pattern reduces. For powder diffraction, Lorentz factor is $1/(sin^22\theta \cos\theta)$.

Cystals with more than one kind of atom in a unit cell can be referred to as interpenetrating lattices. The observed reflection is a composite of the reflected waves from individual lattices with same wavelengths and periods but different amplitudes resulting from their partial interferences. These effects due to atomic arrangements in the intensity from a plane is called *structure factor* $F_{(hkl)}$. It is the ratio of the amplitude scattered by plane relative to the amplitude scattered by single electron. If (hkl) are the Miler indices of the set of the diffracted planes, and f_j is the atomic scattering factor of the j^{th} atom with position (x_j, y_j, z_j) in the lattice then structure factor (F_{hkl}) in the exponential form is expressed as,

$$F_{hkl} = \sum_{j=1}^{N} f_j \exp\{2\pi i (hx_j + ky_j + lz_j)\}$$
(2.5).

As CeO₂ has an face centered cubic lattice , the cerium atoms (Ce⁴⁺) are situated at (0,0,0), (1/2,1/2,0), (1/2,0,1/2) and (1/2,1/2,0) positions. Similarly, oxygen atoms are present in tetrahedral interstitials of the unit sell at (1/4,1/4,1/4), (1/4,1/4,3/4), (1/4,3/4,1/4), (1/4,3/4,3/4), (3/4,1/4,1/4), (3/4,1/4,3/4), (3/4,3/4,1/4), (3/4,3/4,3/4) positions. Scattering factor is same for all cerium ions (f_1) and same for all oxygen atoms (f_2). Hence total structure factor contribution from cerium atoms is,

$$F_{hkl_1} = f_1 \left(1 + e^{\pi i(k+l)} + e^{\pi i(h+l)} + e^{\pi i(h+k)} \right)$$
(2.6)

and from oxygen atoms is,

$$F_{hkl_2} = f_2(e^{\frac{\pi}{2}i(h+k+l)} + e^{\frac{\pi}{2}i(h+k+3l)} + e^{\frac{\pi}{2}i(h+3k+l)} + e^{\frac{\pi}{2}i(h+3k+3l)} + e^{\frac{\pi}{2}i(3h+k+l)} + e^{\frac{\pi}{2}i(3h+3k+l)} + e^{\frac{\pi}{2}i(3h+3k+3l)}) (2.7).$$

Therefore, the total structure factor contribution from both the atoms is,

$$F_{hkl} = F_{hkl_1} + F_{hkl_2} \tag{2.8}$$

It follows from the equation (2.6) that F_{hkl1} is zero unless (*hkl*) are all either even or odd. On the other hand, F_{hkl2} is also zero if (*hkl*) are all odd. Since intensity of the peaks (*I*) is directly proportional to square of the structure factor ($/F_{hkl}/^2$), oxygen atoms do not contribute at all for the lines (111), (311), (331) and (333). Contributions by cerium and oxygen atoms to the each peak intensity are explained below in Table 9.

Plane	20	Ce	0	Ce + O	Contributing	р
		Contribution	Contribution	Contribution	Atoms	
(111)	28.48	$4f_1$	0	$4f_1$	Ce	8
(200)	33.02	$4f_1$	-8f ₂	$4f_1 - 8f_2$	Ce, O_2	6
(220)	47.40	$4f_1$	$+8f_{2}$	4f1 + 8f2	Ce, O_2	12
(311)	56.29	$4f_1$	0	$4f_1$	Ce	24
(222)	59.07	$4f_1$	-8f ₂	4f1 + 8f2	Ce, O_2	8
(400)	69.41	$4f_1$	8f ₂	$4f_1 + 8f_2$	Ce, O ₂	6
(331)	76.73	$4f_1$	0	$4f_1$	Ce	24
(420)	79.14	$4f_1$	-8f ₂	4f1 + 8f2	Ce, O_2	48
(422)	88.48	$4f_1$	$+8f_{2}$	$4f_1 + 8f_2$	Ce, O_2	24
(333)	95.46	$4f_1$	0	$4f_1$	Ce	8

Table 9: Structure Factor Contribution from Cerium & Oxygen Atoms in XRD Diffraction

In theoretical calculations, the diffracted ray is considered from only one atomic plane but in reality diffracted planes from similar planes superimpose to form a stronger intensity ray which is accounted by the factor p called multiplication factor. This factor depends on the symmetry of the atomic crystal. The multiplication factor (p) for a line is number of (hkl) lines planes with same d-spacing. For example the miller indices triplet (111) has a total of 8 combinations including positive and negative values. So the diffraction line has intensity contribution from all these 8 planes and hence 8 times stronger than one (111) plane. The magnitudes of p for various (hkl) lines are listed in Table 4. When a radiation is passed through the crystal, the radiation is partially absorbed which decreases the amount of beam reflected. This is due to scattering and partly due to increase in thermal energy. And finally, the intensity of the diffraction pattern decreases as the temperature of the substance increases. This is due to increase in vibrations of the atoms i.e. the atoms displace from their mean position on the average.

3. Magnetic Properties

As mentioned in first chapter, there are several reports of finding magnetism in diamagnetic cerium oxide. As Cu^0 and CeO_2 both are diamagnetic it would be very interesting to see whether doping copper into cerium oxide would show magnetism or not. If ferromagnetism is shown then, magnetism may be an intrinsic property of the material. Usually there are two kinds of magnetic measurements done. One is measuring magnetization M per unit mass by a magnetometer in a static field H and other is magnetic resonance in which additional radio frequency field with frequency v is applied to cause transitions between Zeeman levels. In this thesis changes in magnetization M observed with change in particles sizes for undoped samples and with change in doping concentration for doped samples are reported as a function of temperature and magnetic field using a magnetometer.

3.1 SQUID Magnetometer

3.1.1 Undoped Cerium Oxide

A commercial superconducting quantum interface device (SQUID) magnetometer was used for magnetization measurements. Reciprocating sample option (RSO) mode of operation was used in which each measurement is taken by rapidly moving the sample in between the SQUID pickup coils. The sample is moved up and down sinusoidally in between the pickup coils and SQUID response for the magnetic moment of the sample is measured. Magnetic property measurement system (MPMS) MultiVu software is used to collect and analyze the data. The data is collected at different range of temperatures i.e. from 2 K to 370 K. The sample is put in a transparent drinking straw and is attached to the tip of a long rod placed inside the dewar. The magnetic data is corrected for the straw with diamagnetic susceptibility of -2.3×10^{-8} emu,

leading to:

$$M_{measured} = M_{sample} + M_{straw} \tag{3.1}$$

Therefore,

$$M_{sample} = M_{measured} + H * 2.3 \times 10^{-8} emu$$
 (3.2).

In Eq.(3.2), M_{measured}, M_{sample}, M_{straw} and H are the measured magnetization, actual magnetization of the sample, diamagnetic component of the straw and applied magnetic field in Oersteds (Oe) respectively. In this work, magnetization M was measured as a function of temperature from 2 K to 370 K in a fixed applied field H and as a function of magnetic field up to \pm 65 kOe at selected temperatures. The magnetic susceptibility is $\chi = M/H$. In the χ vs H measurements, the sample is initially cooled to 2 K in zero magnetic field. After reaching 2 K, a fixed field is applied and the temperature is increased stepwise to 370 K, while taking the data at each temperature. This mode gives the Zero Field Cooled (ZFC) case. Once 370 K is reached, the sample is cooled stepwise back to 2 K in the same field, while taking the data at each stabilized temperature. This is the Field Cooled (FC) case. In this work, χ vs T measurements were taken at 500 Oe. SQUID measurements of undoped CeO₂ samples have been taken on the T_a = 25°C (as prepared), 400°C & 800°C annealed samples. All of the Cu-doped samples Cu_xCe₁. _xO₂ (x = 0.025, 0.05, 0.075 & 0.1) annealed at 400°C have been run for SQUID measurements.

Figure 16 shows the χ vs T plots for undoped CeO₂ samples. The bump in Figure 16 (a) near 75 K for the ZFC case is likely due to trapped oxygen in the straw. Using modified Curie law, a fitting is done to one of the curves (ZFC or FC) to calculate the magnetic moment per atom in the samples. This fitting also provides important magnetic values like Curie constant (C) and molecular field constant (λ).



Figure 16: χ vs T Plots of the Undoped CeO₂ Samples

The magnetization *M* per mole of *N* (Avogadro number) number of electrons each with a magnetic dipole moment μ is M = N μ when they are perfectly aligned. As electron magnetic dipole is caused by the spin of the electron it can be written in terms of angular spin moment as $\mu/\mu_B = g\sqrt{S(S+1)}$ where μ_B is the Bohr magneton, g is the g-factor and S is the magnitude of the spin. g-factor is a dimensionless magnetic moment constant which characterizes magnetic moment and gyromagnetic ratio of an electron. Currently accepted g-value for a free electron is -2.002319 [29]. However, in solids, g-value of the electron can be quite different from 2 due to

the effects of crystal field and spin-orbit interaction. The magnetization of the non-interacting dipoles is directly proportional to the applied magnetic field H and inversely proportional to the temperature T. This is called the Curie Law [29].

$$M = \frac{CH}{T} \text{, where } C = \frac{N\mu^2}{3k}$$
(3.3)

Hence,
$$\chi = \frac{c}{T}$$
 (3.4)

In Eq. 3.3, C is the Curie constant, k is Boltzmann constant and χ is the interaction susceptibility. Weiss replaced all electron-electron interaction by an effective field $H_{int} = \lambda M$ where λ is molecular field constant, thus modifying the Curie law to

$$M = \frac{C(H+H_{int})}{T} = \frac{C(H+\lambda M)}{T}$$
(3.5)

From equation 3.5,

$$\chi = \frac{M}{H} = \frac{\frac{C}{T}}{1 - \frac{C\lambda}{T}} = \frac{C}{T - C\lambda}$$
$$\chi = \frac{C}{T - \theta} \quad \text{, where } \theta = C \lambda \tag{3.6}$$

Equation (3.6) is called the Curie-Wiess law. If θ is positive then the materials is ferromagnetic and if θ is negative then the material is antiferromagnetic. Curie law best fits to the paramagnetic materials or paramagnetic part of the data. Below is brief explanation for finding magnetic moment using χ vs T plot. Using the modified Curie-Weiss law:

$$\chi = \chi_0 + \frac{c}{T - \theta} \tag{3.7}$$

where χ_o takes into account other contribution to susceptibility such as from diamagnetism (- χ_d H) of inner cores which is negative and Van Vleck susceptibility (χ_{vv} H) which is positive. Both χ_d and χ_{vv} are usually temperature independent. Using χ vs 1/T plot, y-intercept in the limit $1/T \rightarrow 0$ yields χ_0 . Values of C and θ are found by plotting a graph $1/(\chi_0)$ vs T where $-\theta/C$ is the y-intercept and 1/C is slope of the plot. (χ_0) is the magnetic susceptibility remained after removal of diamagnetic and Van Vleck magnetic parts. Now the magnetic moment per Bohr magneton (μ/μ_B) in undoped samples is calculated using the equation given below,

$$\frac{\mu}{\mu_B} = \sqrt{\frac{3 k_B * Mol.Wt * C}{(N * \mu_B^2)}}$$
(3.8)

where Mol. Wt. is the molecular weight of the copper doped ceria. The values of χ_o , C and θ and are adjusted accordingly to fit the curve. As noted later, the magnitude of C so determined from the χ vs T at low fields contains both the paramagnetic and ferromagnetic components.



Figure 17: Fitted Chi Plots of Undoped CeO₂ Samples

Table 1	0: Parameter	s of the Fit to	Modified	Curie-Weiss	Law
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T _a (°C)	Particle Size (nm) (XRD)	χο (10 ⁻⁷ emu gm ⁻¹ Oe ⁻¹)	C (10 ⁻⁵ emu K g ⁻¹ Oe ⁻¹)	О (К)
25	2.9	1.63 ± 0.10	1.28 ± 0.04	-1.2 ± 0.1
400	5.7	1.54 ± 0.20	0.28 ± 0.02	$\textbf{-0.6} \pm 0.2$
800	42	2.90 ± 0.10	0.18 ± 0.01	-0.8 ± 0.2

Parameters derived in Table 10 show that there is steady reduction in Curie constant with increase in particle size. This can be attributed to reduction in Ce^{3+} ions in the particles [30]. From this it can be concluded that with decreasing particle size there is increase in paramagnetic

component of magnetization. This is possible only by increase in contribution from Ce^{3+} ions. And the negative values of θ show that the interaction between the dipoles is antiferrromagnetic. Antiferromagnetism is case where magnetic dipoles are aligned anti parallel to each other in an applied magnetic field. This reduces the effective magnetism due to dipole-dipole interaction. Figure 18 below shows the comparison of ZFC and FC plots of undoped CeO₂. These graphs show an increasing magnetic susceptibility with decreasing annealing temperatures thus decreasing particle size. This is true both at 300 K and at 5 K. This effect therefore can be related to the nanosize effects in CeO₂.





Additional information on the nature of magnetism is determined from the M vs H plots which are usually linear for paramagnets and non-linear for ferromagnets. If hysteresis is observed, then remanence M_R and coercivity H_C are measured which yield important information on the ferromagnetic state. As shown in Fig.19, a very small hysteresis is observed both at 300K and 5K, with coercivity $H_C \sim 50$ Oe. But plots at 300 K are more non-linear and show more ferromagnetism. The results are similar for the three undoped samples annealed at $T_a = 25^{\circ}C$, $400^{\circ}C$ and $800^{\circ}C$.



Figure 19: M vs H Plots of the Undoped Cerium Oxide

The graphs in Figure 19 show the presence of both ferromagnetism and paramagnetism in undoped samples. Uniform increase in magnetism at higher fields (straight positive slope) and the hysteresis at the centre in the M vs H curves show the paramagnetic and ferromagnetic part magnetization of the samples respectively. Ferromagnetic part of the graphs can be retrieved from the graphs in Figure 19 by removing the paramagnetic part. The slope of the hysteresis curve at higher fields gives paramagnetic susceptibility (χ_P) since the ferromagnetic component is expected to saturate at higher fields. Subtracting the paramagnetic magnetization (χ_P H) from the magnetization of the sample (M) gives the ferromagnetic part of the plot (Fig. 20). The saturation magnetization M_s, magnetic moment per atom (μ/μ_B), can be calculated using the equation

$$\frac{\mu}{\mu_B} = \frac{M_S * Mol.Wt.}{N * \mu_B}$$
(3.9).

where Mol. Wt. is the molecular weight of cerium oxide (172.11). Table 10 below shows the parameters derived from the M vs H plots taken at room temperature (300 K). In table 10, H_C is the coercive field and M_R is the remanence. Remanence is the M value at H = 0 in the hysteresis loops (see inset of Fig. 19).



Figure 20: Saturation Magnetization (M_S) of Undoped Samples

Ta	χρ	H _C	M _R	Ms	μ/μ _Β
(°C)	$(10^{-7} \text{ emu g}^{-1} \text{ Oe}^{-1})$	(Oe)	$(10^{-5} \text{ emu g}^{-1})$	$(10^{-4} \text{ emu g}^{-1})$	(10^{-4})
25	0.72	70	1	0.86	0.026
400	0.68	55	1	0.85	0.025
800	0.94	50	2	1.50	0.050

Table 8: Parameters Derived from M vs H Plots

Figure 21 compares the 300 K and 5 K M vs H plots of as prepared and $T_a = 400^{\circ}$ C and 800°C annealed samples of undoped ceria. The linear slopes at higher magnetic fields suggest the paramagnetism in the sample and non-linear at lower magnetic fields suggest small ferromagnetism. At 5 K, it can be clearly inferred that with annealing temperatures, paramagnetic magnetization reduces i.e. as particle size increases paramagnetic magnetization decreases. This suggests the increase in Ce³⁺ concentration as particle size reduces. This was earlier discussed while deriving Curie constant values in Table 9. Though a very small amount of ferromagnetism is seen, this is attributed to magnetic impurities as follows: The level of Fe

impurity in undoped cerium oxide annealed at $T_a = 400^{\circ}$ C was found to be 18ppm determined by ICPOES (Gailbraith labs as mentioned in chapter 1). Usually Fe oxidizes easily to either α -Fe₂O₃ (Maghemite) or Fe₃O₄ (Magnetite). α -Fe₂O₃ is only weakly magnetic at room temperature where as saturation magnetization of the bulk Fe₃O₄ is about 92 emu/gm with M_S decreasing with smaller Fe₃O₄ particles [31]. Assuming M_S ~ 92 emu/gm and 18ppm of iron impurity concentration it would yield 1.8 x 10⁻⁴emu/gm as maximum possible magnetization from the Fe₃O₄ impurities. The calculated M_S values are comparable to the observed M_S in Fig. 20. Therefore it is possible that Fe impurities are responsible for the observed ferromagnetism in the undoped CeO₂. The decrease in the ferromagnetic components with increase in annealing temperature can be explained if Fe₃O₄ converts to α - Fe₂O₃ at higher temperatures to complete the oxidation process. This conclusion contradicts other claims of intrinsic ferromagnetism in undoped CeO₂ [8].



Figure 21: M vs H Comparison Plots of Undoped CeO₂



3.1.2 Cu-doped Cerium Oxide

Figure 22: χ vs T Plots of Cu-doped CeO₂

Figure 22 shows the χ vs T plots for the Cu-doped cerium oxides sample. Curie-Weiss law fit is done to find θ and Curie constant C from which magnetic moment (μ) per copper atom can be calculated. To find θ and C, the same procedure used for the undoped samples have been used here. Next, magnetic moment per Bohr magneton (μ / μ_B) is calculated using the equation:

$$\frac{\mu}{\mu_B} = \sqrt{\frac{3 k_B * Mol.Wt * C}{(x * N * \mu_B^2)}}$$
(3.8)

here x is the percentage of copper doping and Mol. Wt. is the molecular weight of the copper doped ceria. In Figure 23, the solid line are the fits to the Curie-Weiss law with the parameters of the fit listed in Table 11.



Figure 23: Curie-Weiss Fits to the χ vs T Data in Cu-doped CeO₂ Samples.

Cu %	χο (10 ⁻⁷ emu gm ⁻¹ Oe ⁻¹)	C (10 ⁻⁵ emu K g ⁻¹ Oe ⁻¹)	0 (К)	$\mu/\mu_{\rm B}$ (10 ⁻⁴)
2.5	3.0 ± 0.3	3.9 ± 0.1	-0.6 ± 0.2	1.43
5	2.0 ± 0.2	7.0 ± 0.8	-3.0 ± 0.3	1.37
7.5	7.1 ± 0.1	6.6 ± 0.3	-2.3 ± 0.1	1.07
10	7.0 ± 0.2	9.3 ± 0.1	-0.6 ± 0.2	1.04

Table 9: Magnetic Moment (μ) per Copper Atom Calculations from χ vs T

Comparison with the magnitudes of C for undoped samples on Table 9 shows that doped samples have larger Curie constant values than undoped samples. This directly indicates the contribution of magnetism from Cu^{2+} which increases with increasing doping concentration. Decreasing magnetic moment (μ) with doping percentage indicates the increase in Cu-Cu ion antiferromagnetic interaction. This is also supported by the negative values of θ . In Figure 24, χ vs T plots are compared for the samples with different Cu doping. The observed increase in C for larger dopings results in the larger χ .



Figure 24: Comparison of ZFC and FC Plots of Cu-doped CeO₂

Next the hysteresis plots of Cu-doped cerium oxide are plotted in Figure 25 with the evaluated parameters listed in Table 12. Both paramagnetism and ferromagnetism is evident. Magnetic moment per copper atom is calculated by finding saturation magnetization M_S values. This is done in a similar fashion as done for undoped samples. Magnetic moment is calculated using the equation:

$$\frac{\mu}{\mu_B} = \frac{M_{S^*} Mol.Wt}{x^* N^* \mu_B}$$
(3.9)

where x is the percentage of copper doping.





Figure 25: M vs H Plots for Cu-doped Samples

Cu %	χ _P (10 ⁻⁷ emu gm ⁻¹ Oe ⁻¹)	H _C (Oe)	$M_{\rm R}$ (10 ⁻⁵ emu g ⁻¹)	$\frac{M_{S}}{(10^{-4} \text{ emu g}^{-1})}$	$\mu/\mu_{\rm B}$ (10 ⁻⁴)
2.5	1.9	50	5.0	2.5	2.92
5	3.5	30	3.0	1.6	1.31
7.5	4.3	106	8.0	5.0	2.18
10	5.0	80	8.5	5.7	1.66

Table 10: Magnetic Parameters Extracted using M vs H Plots

Derived parameters from the M vs H plots show that with increase in doping concentration there is a considerable increase in coercivity (H_C), remanence (M_R) and saturation magnetization (M_S). Exception is the 5% sample. The values of saturation magnetization are larger than those in undoped samples. This is illustrated in Figure 26, suggesting Cu²⁺ ions are responsible for intrinsic ferromagnetism shown in these samples. The important aspect to note is that when Cu²⁺ is doped into lattice replacing Ce⁴⁺, oxygen vacancies have to be created for the reasons of charge balance. Oxygen vacancies may be one of the factors contributing to the ferromagnetism. As mentioned in first chapter oxygen vacancies are known to be reason for ferromagnetism [2, 7, 8, 10]. Although report by Liu et. al. [9] suggest this is not to be the case.



Figure 26: M_S Comparison in Cu-doped Cerium Oxide Samples

Figure 27 shows the M vs H plots of Cu-doped CeO₂ measured at 5 K and 300 K. At both the temperatures net magnetization has increased consistently with increase in doping concentration. This shows that Cu^{2+} ions are playing an important role in producing intrinsic magnetism in the nanoparticles. Electron magnetic resonance (EMR) studies done on these samples by my colleague, Dr. Vivek Singh, have shown the presence of Cu^{2+} ions in the Cu-doped samples.



Figure 27: Comparison of M vs H in Cu-doped CeO₂ Samples

4. Summary and Conclusions

In this thesis, synthesis, structural characterization and magnetic properties of Cu-doped cerium oxide nanoparticles are presented. These results are compared with results from pure or undoped CeO₂. Structural properties were studied using transmission electron microscope (TEM) and x-ray diffraction (XRD) studies. Magnetic measurements were done using superconducting quantum interface device (SQUID) magnetometer. An attempt was made to relate the magnetic changes with the structural changes in the nanoparticles. The summary and conclusion of this work are summarized in this chapter.

The nanoparticles of CeO₂ and Cu-doped CeO₂ were synthesized using a sol-gel process.CeO₂ nanoparticles were prepared with different particle sizes without formation of any other phases. Using the XRD and TEM techniques, particle sizes of the nanoparticles were found to be 2.9nm for as prepared CeO₂ and 3.3 nm, 5.7 nm, 6.7 nm, 19.7 nm and 41.6 nm for samples annealed at Ta = 200°C, 400°C, 550°C, 700°C and 800°C respectively. Steady increase in particles sizes on increase in T_a is explained on the basis of Oswald ripening. As in undoped samples, presence of any impurity phases could not be detected in Cu/CeO₂ in XRD. Particle sizes of doped CeO₂ were nanoparticles were 5.2 nm, 5.5 nm, 4.4 nm and 5.3 nm for Cu_xCe_{1-x}O₂ with x = 0.025, 0.05, 0.075 and 0.1 respectively annealed at Ta = 400°C. Particle sizes from XRD and TEM results are comparable.

Strain and lattice constant value have been derived from XRD patterns. In undoped CeO_2 , samples a uniform decrease in lattice constant and strain was observed with increase in particle size. The decrease in the lattice constant with increase in particle size is likely due to reduction in the percentage of Ce^{3+} ions. In Cu-doped CeO_2 samples an increase in the lattice constant has

been observed for x upto 0.075 followed by a decrease for the x=0.10 sample. This change may be due to Cu²⁺ going into the interstitial sites for larger dopings.

Magnetic studies on all the samples were done using a SQUID magnetometer both as a function of temperature at a fixed magnetic field and as a function of magnetic field at the fixed temperature of 5 K and 300 K. The data of χ vs T were analyzed using the modified Curie-Weiss law from which the Curie constant is determined. For the undoped sample, decrease in C with increase in T_a and the resulting larger particle size is explained in terms of decrease in the concentration of paramagnetic Ce³⁺ ions. The observed ferromagnetic part in the hysteresis is likely due to magnetic impurities of Fe3O₄ and α - Fe₂O₃ at the ppm level.

Copper doped cerium oxide samples showed consistent increase in magnetization with increase in copper doping concentration both at room temperature and at 5 K. Curie constant C and saturation magnetization M_s were found to increase with doping concentration suggesting increase in both paramagnetic part and ferromagnetic part respectively. From both hysteresis and susceptibility curves magnetic moment per copper atom was found to decrease with increasing copper concentration possibility due to increasing $Cu^{2+}-Cu^{2+}$ interaction. The saturation magnetization of the ferromagnetic part is found to increase with doping concentration. This is suggested to be due to increase in the Cu^{2+} ions.

In summary, the room temperature ferromagnetism in undoped CeO₂ is very likely due to invariable Fe₃O₄/ α - Fe₂O₃ impurities present at ppm levels in the starting materials used in the synthesis. However, for the Cu-doped samples, the observed increase in the ferromagnetic component with increasing Cu concentration can only be explained in terms of intrinsic ferromagnetism due to Cu²⁺ doping into CeO₂.

5. Appendix

Calculation of 5% Copper doped Cerium Oxide:

Molecular weight of the cerium nitrate hexahydrate ($Ce(NO_3)_3.6H_2O$) = 434.22

Molecular weight of the copper nitrate hemipentahydrate (Cu(NO₃)₂ . $2\frac{1}{2}$ H₂O) = **236.6**

The nitrate salts are mixed in the atomic ratios of 0.95 (Ce) and 0.05 (Cu). Therefore the ratio in which the nitrate salts are mixed is

 $\frac{Amount \ of \ cerium \ nitrate \ hexahydrate \ (g)}{Amount \ of \ copper \ nitrate \ hemipentahydrate \ (g)} = \frac{0.95 \ x \ 434.22}{0.05 \ x \ 236.6} = \frac{412.509}{11.83}$

Therefore to maintain 5% atomic ratio, 412.509 g of cerium nitrate hexahydrate is mixed with 11.83 g of copper nitrate hemipentahydrate is added. Similarly, for 4.34114 g of cerium nitrate hexahydrate, 0.1245 g of Copper Nitrate Hemipentahydrate is mixed to maintain 0.95:0.05 atomic ratio.On the basis of similar calculation Table 1 resembles the amounts of samples to be mixed to maintain respective atomic ratios.

6. References

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